

Super-resolving Properties of Metallodielectric Stacks

Nkorni Katte¹, Joseph Haus¹, Jean-Bosco Serushema¹, Michael Scalora²

1 Electro-Optics Program, University of Dayton,
Dayton, OH 45469

2 Charles M. Bowden Research Center, AMSRD-
AMR-WS-ST, RDECOM, Redstone Arsenal, AL
35898-5000



Report Documentation Page				Form Approved OMB No. 0704-0188	
Public reporting burden for the collection of information is estimated to average 1 hour per response, including the time for reviewing instructions, searching existing data sources, gathering and maintaining the data needed, and completing and reviewing the collection of information. Send comments regarding this burden estimate or any other aspect of this collection of information, including suggestions for reducing this burden, to Washington Headquarters Services, Directorate for Information Operations and Reports, 1215 Jefferson Davis Highway, Suite 1204, Arlington VA 22202-4302. Respondents should be aware that notwithstanding any other provision of law, no person shall be subject to a penalty for failing to comply with a collection of information if it does not display a currently valid OMB control number.					
1. REPORT DATE 2010		2. REPORT TYPE		3. DATES COVERED 00-00-2010 to 00-00-2010	
4. TITLE AND SUBTITLE Super-Resolving Properties Of Metallodielectric Stacks				5a. CONTRACT NUMBER	
				5b. GRANT NUMBER	
				5c. PROGRAM ELEMENT NUMBER	
6. AUTHOR(S)				5d. PROJECT NUMBER	
				5e. TASK NUMBER	
				5f. WORK UNIT NUMBER	
7. PERFORMING ORGANIZATION NAME(S) AND ADDRESS(ES) AMSRD-AMR-WS-ST, RDECOM, Charles M. Bowden Research Center, Redstone Arsenal, AL, 35898				8. PERFORMING ORGANIZATION REPORT NUMBER	
9. SPONSORING/MONITORING AGENCY NAME(S) AND ADDRESS(ES)				10. SPONSOR/MONITOR'S ACRONYM(S)	
				11. SPONSOR/MONITOR'S REPORT NUMBER(S)	
12. DISTRIBUTION/AVAILABILITY STATEMENT Approved for public release; distribution unlimited					
13. SUPPLEMENTARY NOTES Presented at the COMSOL Conference, Boston, MA October 7-9, 2010					
14. ABSTRACT					
15. SUBJECT TERMS					
16. SECURITY CLASSIFICATION OF:			17. LIMITATION OF ABSTRACT Same as Report (SAR)	18. NUMBER OF PAGES 15	19a. NAME OF RESPONSIBLE PERSON
a. REPORT unclassified	b. ABSTRACT unclassified	c. THIS PAGE unclassified			

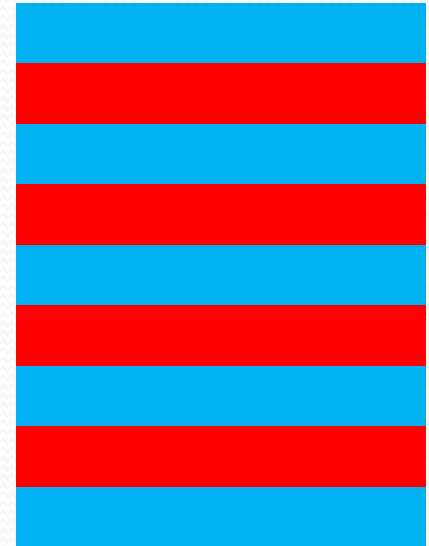
1 Introduction

Conventional optical imaging systems resolve only to about half the wavelength of incident light.

Goals

- UV-Vis wavelengths (400 – 700 nm)
- %T 100x greater than single layer Ag
- $\lambda/12$ spatial resolution

Operation of MDS



*Suppress diffraction
through balance of
positive and
negative refraction*

2 Transmission and Super-resolution regimes

TMM formalism

$$E = (A_{\alpha} \exp(-i \beta_{\alpha} z) + B_{\alpha} \exp(i \beta_{\alpha} z)) \exp(-i \kappa x)$$

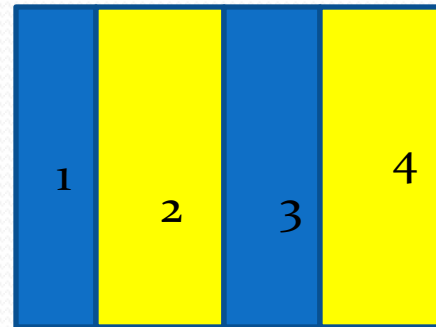
$$\begin{bmatrix} A_1 \\ B_1 \end{bmatrix} = \frac{1}{t_{12}} \begin{bmatrix} 1 & r_{12} \\ r_{12} & 1 \end{bmatrix} \begin{bmatrix} A_2 \\ B_2 \end{bmatrix} = T \begin{bmatrix} A_2 \\ B_2 \end{bmatrix}$$

$$\begin{bmatrix} A \\ B \end{bmatrix} = \begin{bmatrix} \exp(i \phi) & 0 \\ 0 & \exp(-i \phi) \end{bmatrix} \begin{bmatrix} A' \\ B' \end{bmatrix} = P \begin{bmatrix} A' \\ B' \end{bmatrix}$$

$$F = T_1 P_1 T_2 P_2 T_3 P_3 \dots T_n P_n T_{n+1}$$

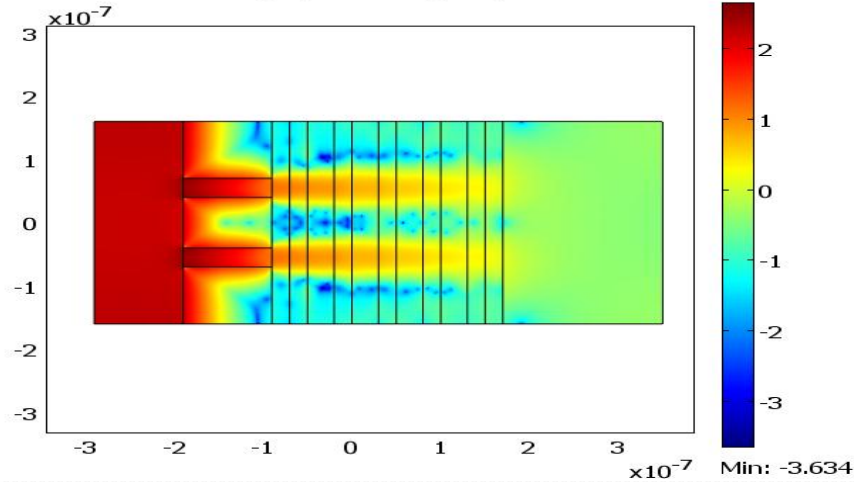
$$F = \begin{bmatrix} f_{11} & f_{12} \\ f_{21} & f_{22} \end{bmatrix}$$

$$R = \left| \frac{f_{21}}{f_{11}} \right|^2, T = \left| \frac{1}{f_{11}} \right|^2$$

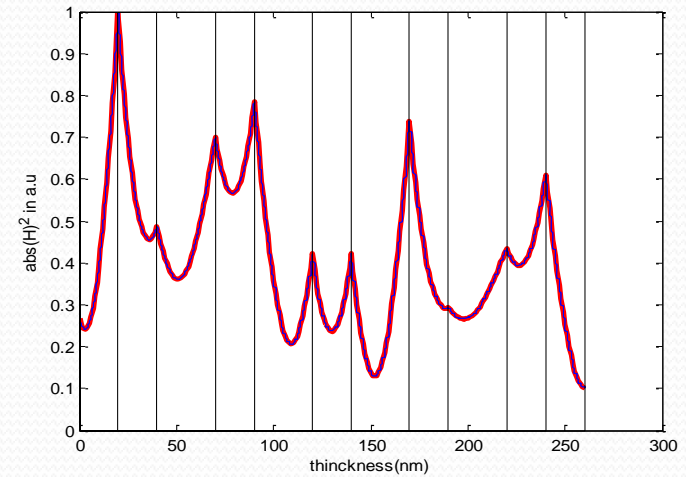
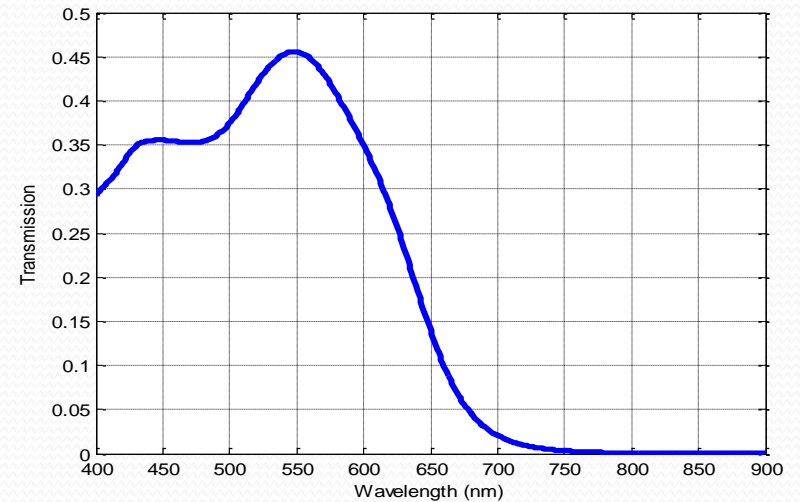
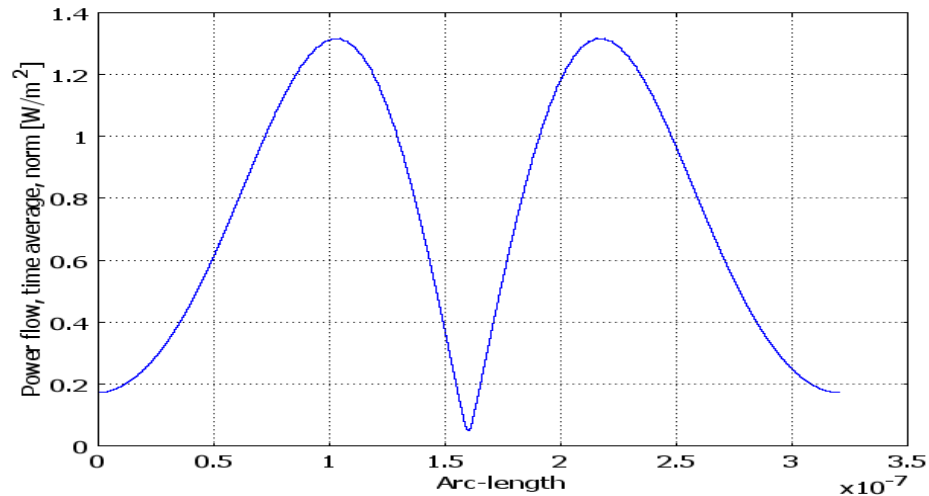


MDS₁

log10(nomPoav_rfw)



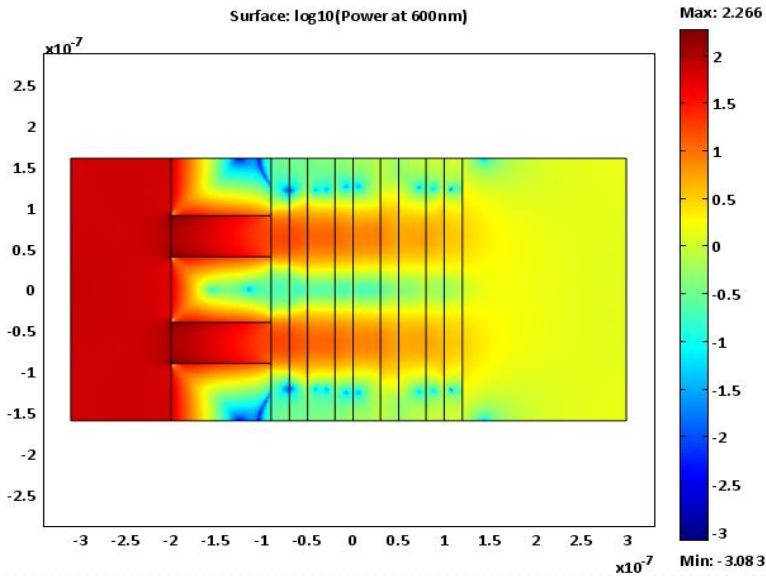
MDS₁: [GaP (20nm)/ 4.5 periods of Ag (20nm)/ GaP (30nm) /GaP (20nm)].



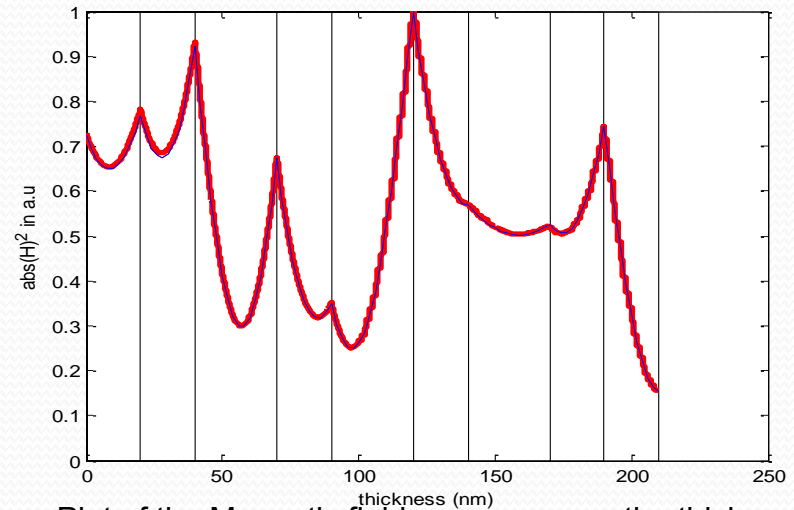
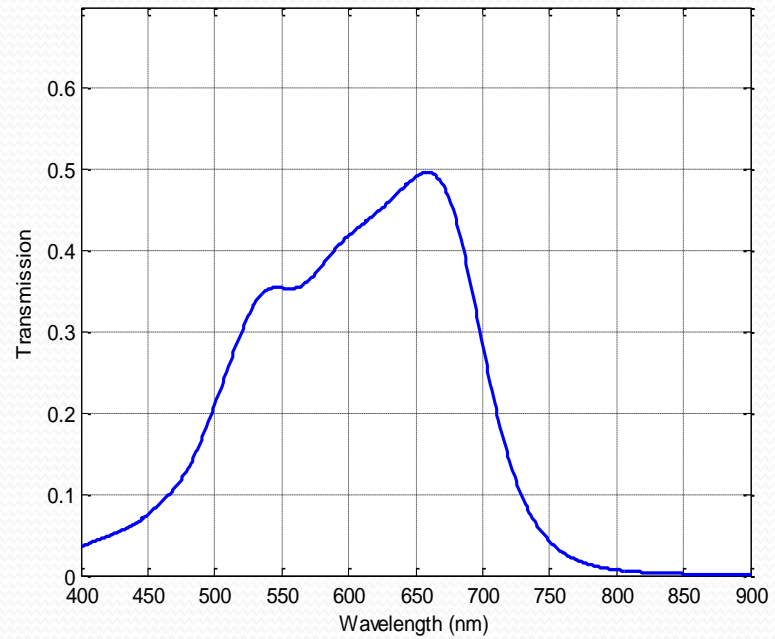
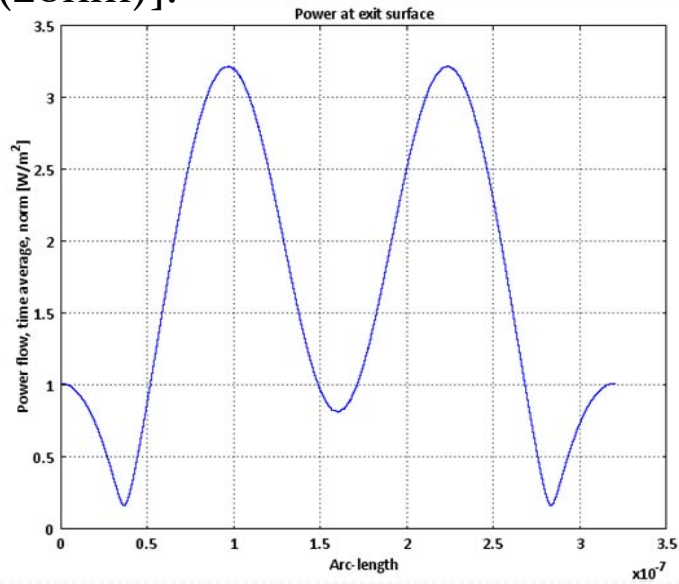
Plot of the Magnetic field squared across the thickness of MDS₁ consisting of Ag and GaP layers. There is an overlay of the red line over the blue line. **The red line is the FEM simulation**. While the blue line is TMM solution. Both methods give a transmission of 44% at an incident wavelength of 532nm.

MDS₂

Surface: $\log_{10}(\text{Power at } 600\text{nm})$

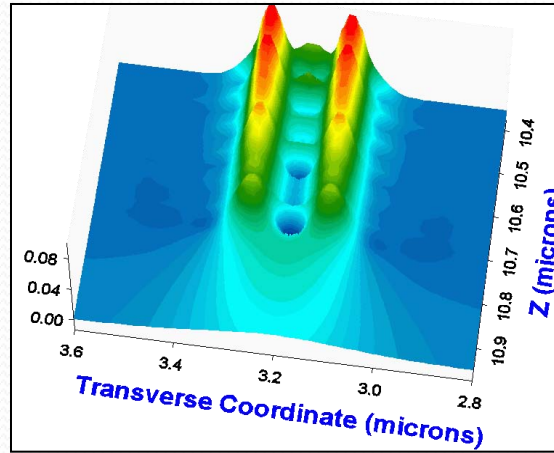
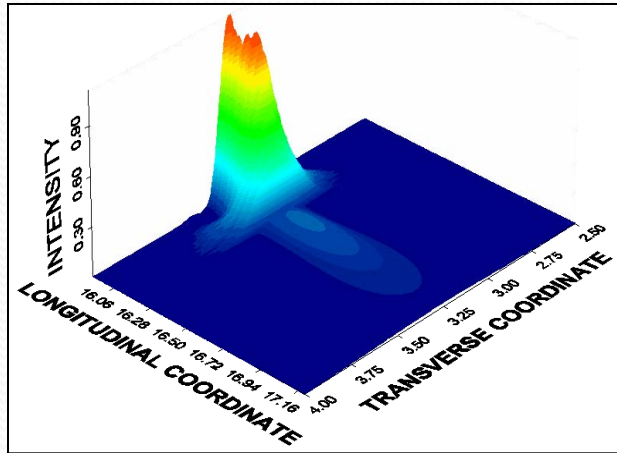


MDS₂: [GaP (20nm)/3.5periods (Au (20nm)/GaP (30nm))/GaP (20nm)].



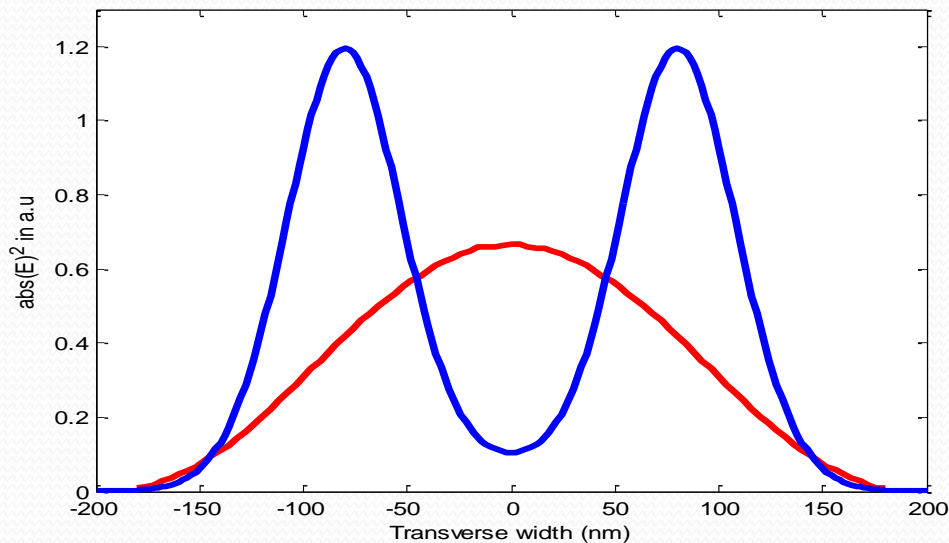
Plot of the Magnetic field square across the thickness of MDS₂ consisting of Au and GaP layers. There is an overlay of the red line over the blue line. **The red line is the FEM simulation**. While the blue line is TMM solution. Both methods give a transmission of 42% at an incident wavelength of 600nm.

Beam Propagation results (Plane-wave method)



Transmission through a MD photonic crystal (the layers are parallel to the transverse coordinate) in the focusing regime ($\lambda=400$ nm), which shows the formation of an external focal spot (left), and in the super-resolving regime (right) showing the super-guiding regime ($\lambda=640$ nm), with two closely spaced $\lambda/20$ channels that do not interfere thanks to the formation of transverse Plasmon waves [4,7].

MDS₃: Limitations of TMM



MDS₃: [TiO₂ (40nm)/ 3.5periods of (Cu (20nm)/TiO₂ (80nm)/TiO₂ (40nm))].

Comsol result: No Super-resolution Diffraction, unsuppressed.

Reason for discrepancy

- TMM field is prescribed on the surface and this is unphysical.
- Comsol the field propagates through a slit and the fields interact with the slit.

Nonlinear Photonics with MDS3

$$\nabla \times \nabla \times \mathbf{E} = -\mu_0 \left(\varepsilon_0 \frac{\partial^2 \mathbf{E}}{\partial t^2} + \frac{\partial^2 \mathbf{P}_L}{\partial t^2} + \frac{\partial^2 \mathbf{P}_{NL}}{\partial t^2} \right)$$

$$\nabla(\nabla \cdot \mathbf{E}) - \nabla^2 \mathbf{E} = -\mu_0 \left(\varepsilon_0 \frac{\partial^2 \mathbf{E}}{\partial t^2} + \frac{\partial^2 \mathbf{P}_L}{\partial t^2} + \frac{\partial^2 \mathbf{P}_{NL}}{\partial t^2} \right)$$

Nonlinear absorption
And Nonlinear refraction
Applications (Optical limiting
and Switching)

$$\mathbf{P}_{NL} = \varepsilon_0 \chi^{(2)} \mathbf{E} \mathbf{E} + \varepsilon_0 \chi^{(3)} \mathbf{E} \mathbf{E} \mathbf{E} + \dots$$

$$E(Z, r, t) = E_0(t) \frac{w_0}{w(Z)} \exp \left(-\frac{r^2}{w^2(Z)} + i \frac{\pi r^2}{\lambda R(Z)} + i \phi \right)$$

$$Z_0 = \frac{\pi w_0^2}{\lambda}$$

For CW $E_0(t) \rightarrow E_0$

$$\chi^{(3)} \propto n_2 + i\beta$$

NL index change

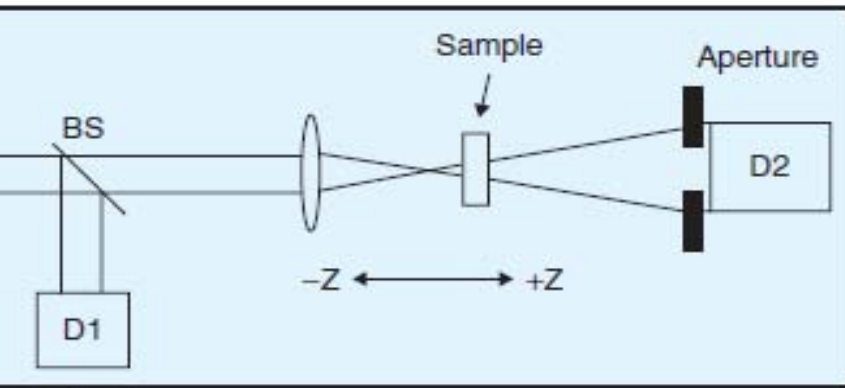
NL (two photon) absorption

Implementation of a Paraxial Optical Propagation Method for
Large Photonic Devices COMSOL Conf 2009
J. E Toney

“Cannot handle systems with arbitrary
propagation directions: Photonic
crystals (photonic band gaps)”

Z scan technique

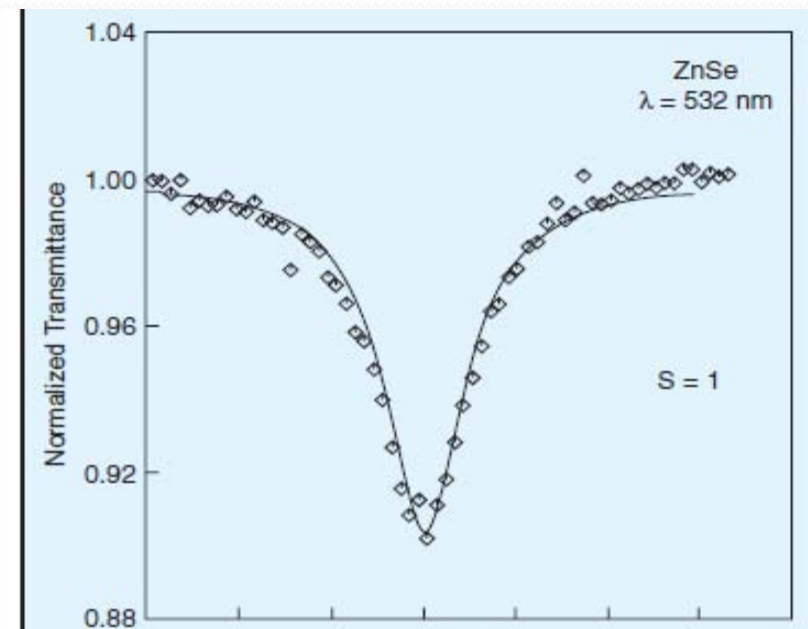
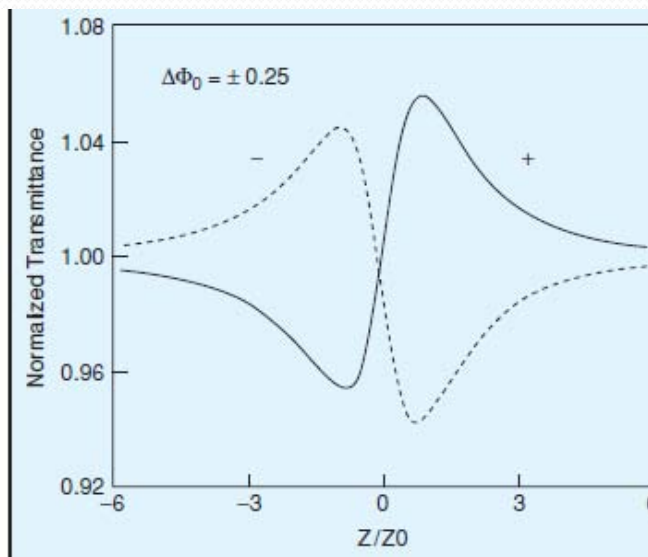
Developed for homogenous material,
reliable for the determination of β and n_2



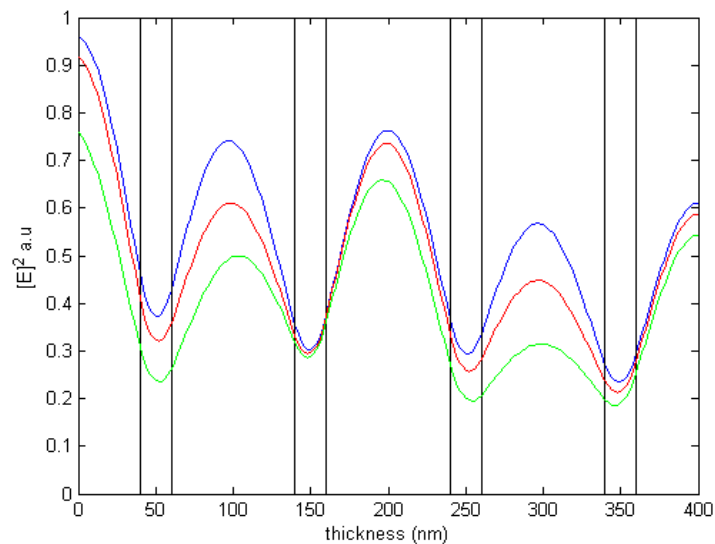
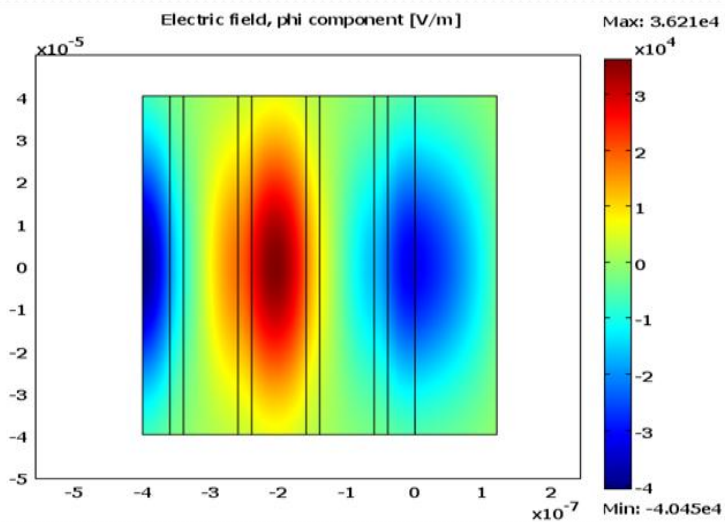
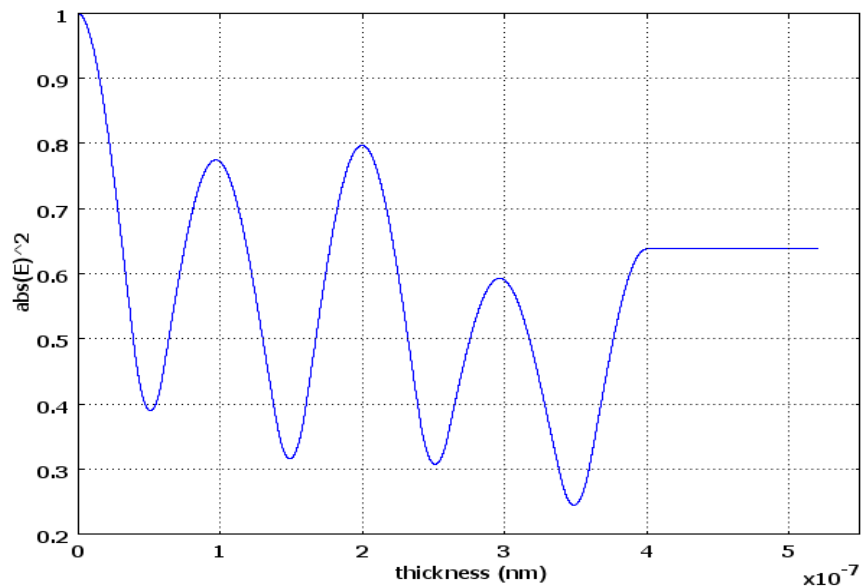
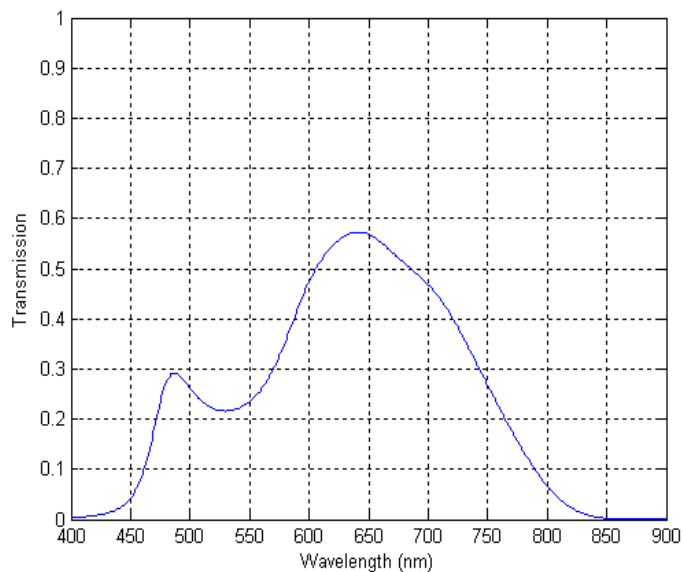
M. Sheik-Bahae, A. A. Said, T. Wei, D. J. Hagan, and E. W. Van Stryland,
“Sensitive measurement of optical nonlinearities using a single beam,”
IEEE J. Quantum Electron. **26**, 760–769 (1990).

$$P_T(\Delta\Phi_0(t)) = c\epsilon_0 n_0 \pi \int_0^{r_0} |E_a(r, t)|^2 r dr$$

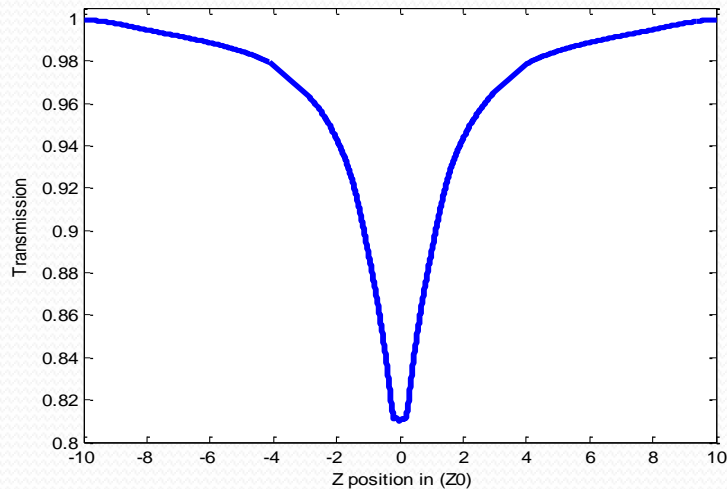
$$E_l(z, r, t) = E(z, r, t) e^{-\alpha L/2} e^{i\Delta\phi(z, r, t)}.$$



Results for MDS₃



Open Aperture Z scan Result



$$\beta = 4.75 \times 10^{-6} \text{ cm/W}$$

$$n_2 = 2 \times 10^{-11} \text{ cm}^2/\text{W}$$

$$w_0 = 20 \mu\text{m}$$

$$T(Z) = \frac{1}{U} \int_{-\infty}^{+\infty} dt \int_0^{r_a} r dr |E_a(Z, r, t, d)|^2$$

$$T(Z) \cong 1 - \frac{4\Delta\phi_0 x}{(x^2 + 9)(x^2 + 1)}$$

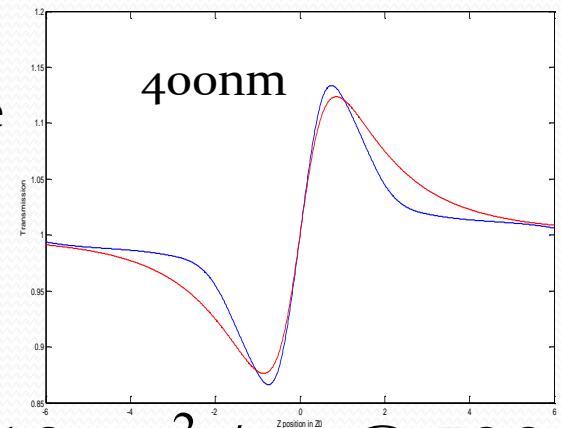
-Simulation of a 1D photonic band gap device such as our MD stack usually includes the losses due to internal multi-interference and back reflections, which contributes to the absorption within each layer .

-Considers transverse effects important in describing the beam profile are neglected [10]. These transverse effects are important for experimental purposes.

-Significant nonlinearity and realistic input beams,

Check for purely nonlinear refractive material,

FEM:blue
ANA:red



$$n_2 = 9e-12 \text{ cm}^2/\text{W} @ 532 \text{ nm}$$

Summary and conclusions

Super-resolution is achieved at various wavelengths with MDS.

Compared **the TMM and the FEM** for Transmission, and Super-resolution. We find that even though both methods yield the same results for Transmission, the standard TMM method fails to accurately predict Super-resolution.

Simulated the propagation of a typical **Gaussian beam** through a nonlinear MDS. The output of this simulation has been used to model the standard CW Z scan experiment, and the results agree very well with the Z scan theory

Future Work : Include temperature dependence for the permittivity and solve a transient problem.

Some References

- [1] J. B. Pendry, "Negative refraction makes a perfect lens," Phys. Rev. Lett. **85**, 3966 (2000).
- [2] M. Scalora et al. "Negative refraction and sub-wavelength focusing in the visible range using transparent metallo-dielectric stacks," Optics Express **15**, 508-523 (2007).
- [3] M. J. Bloemer, G. D'Aguanno, N. Mattiucci, M. Scalora, and N. Akozbek, "Broadband super resolving lens with high transparency for propagating and evanescent waves in the visible range," <http://www.arxiv.org/abs/physics/0611162>.
- [4] D. de Ceglia, M. A. Vincenti, M. G. Cappeddu, M. Centini, N. Akozbek, A. D'Orazio, J. W. Haus, M. J. Bloemer, and M. Scalora, Tailoring Metallodielectric Structures for Super Resolution and Super guiding Application in the Visible and near IR Ranges, Physical Rev. A **77**, 033848 (2008).
- [5] E. D. Palik, Handbook of Optical Constants of Solids (Academic Press, New York, 1985).
- [6] C.P Moore, R. J. Blaikie, M. D. Arnold "An improved transfer-matrix model for optical superlenses", Optics Express **17**(16), 14260 (2009).
- [7] J.W. Haus, N. Katte, J. B. Serushema and M. Scalora, "Metallodielectrics as Metamaterials," "SPIE Optics and Photonics Conference, to appear (2010).
- [8] M. Sheik-Bahae, A. A. Said, T. Wei, D. J. Hagan, and E. W. Van Stryland, "Sensitive measurement of optical nonlinearities using a single beam," IEEE J. Quantum Electron. **26**, 760–769 (1990).

Simulation Details

****Nonlinear Optics Simulation****

Number of Mesh points =4305

Number of Mesh elements 4160

Number of degrees of Freedom=33858